

IDS Form PTO/SB/08: Substitute for form 1449A/PTO  <b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  <i>(Use as many sheets as necessary)</i>				<b>Complete if Known</b>	
				<i>Application Number</i>	10/550,510
				<i>Filing Date</i>	September 23, 2005
				<i>First Named Inventor</i>	Norifumi KIKKAWA et al.
				<i>Art Unit</i>	2442
				<i>Examiner Name</i>	SURVILLO, Oleg
Sheet	1	of	1	<i>Attorney Docket Number</i>	09812.0142-00000

U.S. PATENTS AND PUBLISHED U.S. PATENT APPLICATIONS					
Examiner Initials	Cite No.	Document Number	Issue or Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code <i>(if known)</i>			

FOREIGN PATENT DOCUMENTS						
Examiner Initials	Cite No.	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Translation
		Country Code Number Kind Code <i>(if known)</i>				

NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Translation
/M.C./		Communication from the Japanese Patent Office for Japanese Patent Application No. 2003-088009, dated October 23, 2006, 5 pages.	Yes
/M.C./		Kobayashi Nagako, "Shin-hasso no Data-Warehouse (New Thinking Data Warehouse)", Nikkei Computer, Japan, Nikkei Business Publications, Inc., February 16, 1998, Issue: 437, p. 132-138.	No

Examiner Signature	/Michael Chao/	Date Considered	09/10/2009
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.